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APPLICATION NO.	1	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/700,068		11/03/2003	Mina Farr	15436.250.30.1	3739	
22913	7590	05/12/2005		EXAMINER		
WORKMA			MARTINEZ, JOSEPH P			
(F/K/A WORKMAN NYDEGGER & SEELEY) 60 EAST SOUTH TEMPLE ART UNIT PAPE					PAPER NUMBER	
1000 EAGLE GATE TOWER 2873						
SALT LAK	E CITY,	UT 84111	DATE MAILED: 05/12/2005			

Please find below and/or attached an Office communication concerning this application or proceeding.

				H-A				
		Application No.	Applicant(s)					
		10/700,068	FARR, MINA					
	Office Action Summary	Examiner	Art Unit					
		Joseph P. Martinez	2873					
Period fo	The MAILING DATE of this communication app or Reply	pears on the cover sheet with	the correspondence address	•				
THE - Exte after - If the - If NC - Failt Any	ORTENED STATUTORY PERIOD FOR REPL' MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a repl' period for reply is specified above, the maximum statutory period of the provision of the p	36(a). In no event, however, may a rep y within the statutory minimum of thirty vill apply and will expire SIX (6) MONTI , cause the application to become ABA	ly be timely filed (30) days will be considered timely. IS from the mailing date of this communical NDONED (35 U.S.C. § 133).	tion.				
Status	•							
1)⊠	Responsive to communication(s) filed on <u>08 F</u>	ebruary 2005.						
·	↑ This action is FINAL. 2b) This action is non-final.							
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
	closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D.	11, 453 O.G. 213.					
Disposit	ion of Claims							
4)⊠	○ Claim(s) <u>1-38</u> is/are pending in the application.							
	4a) Of the above claim(s) is/are withdrawn from consideration.							
5)🛛	☑ Claim(s) <u>35-38</u> is/are allowed.							
6)⊠	Claim(s) <u>1-6, 11-17, 22-28, 33 and 34</u> is/are rejected.							
7)⊠	Claim(s) <u>7-10,18-21 and 29-32</u> is/are objected to.							
8) 🗌	Claim(s) are subject to restriction and/or election requirement.							
Applicat	tion Papers							
9)[The specification is objected to by the Examine	er.						
10)🛛	10)⊠ The drawing(s) filed on <u>03 November 2003</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.							
	Applicant may not request that any objection to the	drawing(s) be held in abeyand	e. See 37 CFR 1.85(a).					
	Replacement drawing sheet(s) including the correct	tion is required if the drawing(s) is objected to. See 37 CFR 1.12	1(d).				
11)	The oath or declaration is objected to by the Ex	xaminer. Note the attached	Office Action or form PTO-152	•				
Priority	under 35 U.S.C. § 119							
•	Acknowledgment is made of a claim for foreign All b) Some * c) None of:		119(a)-(d) or (f).					
	1. Certified copies of the priority document2. Certified copies of the priority document		nlication No					
	3. Copies of the certified copies of the prior							
	application from the International Burea	·	cocived in this Hatishai Otage					
*	See the attached detailed Office action for a list		eceived.					
Attachmei								
	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Su Paper No(s).	mmary (PTO-413) /Mail Date					
3) 🔲 Info	rmation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) er No(s)/Mail Date		ormal Patent Application (PTO-152)					

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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-3, 6, 11, 13-15, 22-25, 28 and 33 are rejected under 35 U.S.C. 102(b) as being fully anticipated by Nakatsu et al. (5031991).

Re claims 1, 13 and 23, Nakatsu et al. teaches for example in figs. 3b and 3c, an optical device, an optical system for focusing an optical beam into an input face of an optical fiber (6) or a method of focusing an astigmatic optical beam (col. 5, In. 38-40) comprising: an optical source (5) for producing an optical beam having spaced apart first and second focal points of origin in orthogonal first and second planes of beam propagation of the optical beam (col. 2, In. 30, wherein the office interprets "elliptic far field pattern" to teach the claimed limitation), respectively; a first lens (10) disposed in an optical path of the optical beam and having a first optical focusing power in both the first and second planes of beam propagation (col. 5, In. 52-54, and col. 5, In. 30-38), wherein the first lens is disposed at a first distance (where the office interprets where 10 is placed to disclose a first distance) from the first focal point of origin for generally collimating (col. 5, In. 52-54, and col. 5, In. 30-38) the optical beam in the first plane of beam propagation and for focusing (col. 5, In. 52-54, and col. 5, In. 30-38) the

optical beam down to a first beam diameter in the second plane of beam propagation at an image position located a second distance (where the optical beam meets 6) from the first lens; and a second lens (20) disposed in the optical path of the optical beam and having a second optical focusing power in the first plane of beam propagation and generally no optical focusing power in the second plane of beam propagation (col. 5, ln. 54 and col. 5, ln. 40-50), wherein the second lens is disposed at a third distance (where the office interprets where 20 is placed to disclose a third distance) from the image position for focusing the optical beam down to a second beam diameter in the first plane of beam propagation at the image position (col. 5, ln. 54 and col. 5, ln. 40-50).

Re claims 2, 14 and 24, Nakatsu et al. further teaches for example, the first and second beam diameters are substantially equal to each other (col. 2, In. 32).

Re claims 3, 15 and 25, Nakatsu et al. further teaches for example, at the image position, the optical beam has a numerical aperture in the first plane of beam propagation that is substantially equal to that of the beam in the second plane of beam propagation (col. 2, In. 31, wherein the office interprets "spherical wave" to disclose the claimed limitation).

Re claims 6 and 28, Nakatsu et al. further teaches for example in figs. 3b and 3c, an optical fiber (6) having an input end disposed at the image position for receiving the optical beam.

Re claims 11, 22 and 33, Nakatsu et al. further teaches for example in figs. 3b and 3c, the second lens is a cylindrical lens (col. 5, In, 32-33).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 1. Claims 4-5, 16-17 and 26-27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakatsu et al. (5031991) in view of Pillai (6212216).

Re claims 4-5, 16-17 and 26-27, Nakatsu et al. teaches the optical device, optical system for focusing an optical beam into an input face of an optical fiber or a method of focusing an astigmatic optical beam as disclosed above, including first and second focal lengths (f1 and f2, col. 5, ln. 60 and 65).

But, Nakatsu et al. fails to explicitly teach the first distance is substantially equal to the first lens focal length or the third distance is substantially equal to the second lens focal length.

However, within the same field of endeavor, Pillai teaches for example, varying the position and focal length of the lenses (col. 7, In. 37-42).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the teachings of Nakatsu et al. with the teachings Pillai to have the first distance be substantially equal to the first lens focal length or the third distance be substantially equal to the second lens focal length in order to provide an astigmatically corrected circular beam with waist size equal to the fiber spot size, as taught by Pillai.

2. Claims 12 and 34 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakatsu et al. (5031991) in view of Anthon (6125222).

Re claims 12 and 34, Nakatsu et al. teaches the optical device, optical system for focusing an optical beam into an input face of an optical fiber or a method of focusing an astigmatic optical beam as disclosed above, including for use with a semiconductor laser.

But, Nakatsu et al. teaches fails to explicitly teach the optical source is a master oscillator power amplifier having a diode laser portion for generating the optical beam and a planar waveguide amplifier portion for amplifying the optical beam, and wherein the second focal point of origin is located approximately at a location where the optical beam exits the diode laser portion, and the first focal point of origin is located approximately at a location where the optical beam exits the planar waveguide amplifier portion.

However, within the same field of endeavor, Anthon teaches for example in fig. 1, master oscillator power amplifier having a diode laser portion for generating the optical beam and a planar waveguide amplifier portion for amplifying the optical beam (col. 2, ln. 11-13), and wherein the second focal point of origin is located approximately at a location where the optical beam exits the diode laser portion, and the first focal point of origin is located approximately at a location where the optical beam exits the planar waveguide amplifier portion (wherein the office interprets the claimed features of the master oscillator power amplifier to be well known in the art).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the teachings of Nakatsu et al. to include the master oscillator power amplifier of Anthon in order to provide high beam quality in the slow axis, as taught by Anthon (col. 2, In. 11-13).

Allowable Subject Matter

Claims 35-38 are allowed.

The following is an examiner's statement of reasons for allowance: the prior art taken alone or in combination fails to anticipate or fairly suggest the limitations of the claims, in such a manner that a rejection under 35 USC 102 or 103 would be proper.

The prior art fails to teach a combination of all the claimed features as presented in independent claims 35 and 37.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Claims 7-10, 18-21 and 29-32 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter: the prior art taken alone or in combination fails to anticipate or fairly suggest the limitations of the claims, in such a manner that a rejection under 35 USC 102 or 103 would be proper. The prior art fails to teach a combination of all the claimed features as presented in dependent claims 7, 9, 18, 20, 29 and 31.

Specifically regarding claims 7, 18, 29 and 35, Nakatsu et al. teaches the state of the art of optical coupling devices.

But, Nakatsu et al. fails to explicitly teach the optical beam incident upon the first lens has a second numerical aperture in the second plane of beam propagation; the optical fiber has an acceptance numerical aperture associated therewith; the first and second focal points of origin are separated by a fourth distance; and the second numerical aperture divided by the acceptance numerical aperture is substantially equal to or less than the second distance divided by the sum of the first focal length and the fourth distance, as claimed

Specifically regarding claims 9, 20, 31 and 37, Nakatsu et al. teaches the state of the art of optical coupling devices.

But, Nakatsu et al. fails to explicitly teach the optical beam incident upon the first lens has a first numerical aperture in the first plane of beam propagation; the optical fiber has an acceptance numerical aperture associated therewith; and the first numerical aperture divided by the acceptance numerical aperture is substantially equal to or less than the second focal length divided by the first focal length, as claimed.

Response to Arguments

Applicant's arguments filed 2-8-05 have been fully considered but they are not persuasive.

Re applicant's arguments on p. 14 and 15, wherein the applicant argues that the prior art does not disclose a first lens having the same optical focusing power in both the vertical and horizontal planes of beam propagation, have been considered, but are not persuasive. Fig. 3(b) and 3(c) of Nakatsu et al. correspond to and clearly show what is taught in applicant's fig. 2B, specifically wherein the focusing power of first lens (10 of Nakatsu et al. which corresponds to 12 of instant applicant) to have a first optical focusing power in both the first and second planes of beam propagation (wherein the office interprets the focal length in both planes of propagation to be equal and therefore the corresponding focusing powers are equal).

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Joseph P. Martinez whose telephone number is 571-272-2335. The examiner can normally be reached on M-F 7:00 AM to 3:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Georgia Y. Epps can be reached on 571-272-2328. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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JPM 5-4-05

Hung Xuan Dang Primary Examiner